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	Application No.	Applicant(s)	
	10/082,228	TATSUURA ET AL.	•
Notice of Allowability	Examiner	Art Unit	
	Edna Wong	1753	
The MAILING DATE of this communication apper All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in to or other appropriate commure GHTS. This application is su	his application. If not included ication will be mailed in due course.	THIS initiative
1. A This communication is responsive to Amendment dated Fe	ebruary 25, 2005.		
2. The allowed claim(s) is/are 30-46.			
3. $\boxtimes$ The drawings filed on <u>26 February 2002</u> are accepted by the	ne Examiner.		`
4.  Acknowledgment is made of a claim for foreign priority una	e been received. e been received in Application cuments have been received of this communication to file at IENT of this application. eitted. Note the attached EXAles reason(s) why the oath or est be submitted. est be submitted. est on's Patent Drawing Review	No. <u>09/571,864</u> . in this national stage application from a reply complying with the requirement MINER'S AMENDMENT or NOTICE declaration is deficient.	nts
Paper No./Mail Date  Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in t	.84(c)) should be written on the	drawings in the front (not the back) o	f
7. DEPOSIT OF and/or INFORMATION about the depo attached Examiner's comment regarding REQUIREMENT	sit of BIOLOGICAL MATE	RIAL must be submitted. Note the	•
Attachment(s)  1. Notice of References Cited (PTO-892)  2. Notice of Draftperson's Patent Drawing Review (PTO-948)  3. Information Disclosure Statements (PTO-1449 or PTO/SB/O Paper No./Mail Date  4. Examiner's Comment Regarding Requirement for Deposit of Biological Material	6. ☑ Interview Su Paper No./N 7. ☐ Examiner's A	Mail Date <u>February 24, 2005</u> .  Amendment/Comment  Statement of Reasons for Allowance	<b>R</b>

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## REASONS FOR ALLOWANCE

The following is an examiner's statement of reasons for allowance:

Claims **30-38** are allowable over the prior art of record because the prior art does not teach or suggest an apparatus for electrodeposited film formation comprising an electrolyte solution bath and a mode-locked laser whose pulse with is less than a picosecond.

The prior art does not contain any language that teaches or suggests the above. *Melcher et al.* do not teach a mode-locked laser. Mode-locking inherently creates pulses of picoseconds. The fact that Melcher utilizes a chopper to get pulsing indicates that the continuous multimode or single mode argon laser (col. 3, lines 40-44) is not the same thing as mode-locking. Therefore, a person skilled in the art would not have been motivated to adopt the above conditions, and a prima facie case of obviousness cannot be established.

Claims **39-46** are allowable over the prior art of record because the prior art does not teach or suggest an apparatus for electrodeposited film formation comprising an electrolyte solution bath and a pulse laser with an electric field in the order of tens of GW/cm<sup>2</sup> and whose pulse width is less than a picosecond.

The prior art does not contain any language that teaches or suggests the above. Melcher et al. do not teach a pulse laser with an electric field in the order of tens of GW/cm<sup>2</sup>. Melcher et al. teach an intensity preferably between about 10<sup>2</sup> to 10<sup>6</sup> W/cm<sup>2</sup> (col. 3, lines 48-50). Therefore, a person skilled in the art would not have been Application/Control Number: 10/082,228

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motivated to adopt the above conditions, and a prima facie case of obviousness cannot be established.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Edna Wong whose telephone number is (571) 272-1349. The examiner can normally be reached on Mon-Fri 7:30 am to 4:00 pm, Flex.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nam Nguyen can be reached on (571) 272-1342. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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EW March 21, 2005